

L Number	Hits	Search Text	DB	Time stamp
1	1	("5879741").PN.	USPAT; EPO; JPO	2002/11/25 23:20
-	319	chen-bret\$.xa.	USPAT; EPO; JPO	2002/11/21 18:35
-	75	chen-bret\$.xp.	USPAT; EPO; JPO	2002/11/21 18:49
-	8	("4252837"   "4440107"   "4485125"   "4724169"   "5510151"   "5523126"   "5571749"   "5879741").PN.	USPAT	2002/11/21 18:42
-	212987	canon\$.as.	USPAT; EPO; JPO	2002/11/21 18:49
-	243	canon\$.as. and ((belt web) near4 (substrate\$ wafer\$))	USPAT; EPO; JPO	2002/11/21 18:55
-	237	canon\$.as. and ((belt web) near4 (substrate wafer))	USPAT; EPO; JPO	2002/11/21 18:56
-	237	canon\$.as. and ((belt web) near4 (substrate wafer))	USPAT; EPO; JPO	2002/11/22 14:37
-	905	(h011021\$.ipc. c23c016\$.ipc.) and ((belt web) near4 (substrate wafer))	DERWENT USPAT; EPO; JPO; DERWENT	2002/11/22 11:10
-	2	("4400409"   "5510151").PN.	USPAT	2002/11/22 10:56
-	9	("4978412"   "5227203"   "5275683"   "5575855"   "5589007"   "5695566"   "5851299"   "6025039"   "6271055").PN.	USPAT	2002/11/22 10:57
-	122	(h011021\$.ipc. c23c016\$.ipc.) and ((belt web) near4 (substrate wafer)).ti.	USPAT; EPO; JPO; DERWENT	2002/11/22 11:01
-	111	((h011021\$.ipc. c23c016\$.ipc.) and ((belt web) near4 (substrate wafer)).ti.) not (canon\$.as. and ((belt web) near4 (substrate wafer)))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:13
-	63	(h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:12
-	92	(h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) same (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:21
-	56	((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) with (electrode cathode anode)) not (((h011021\$.ipc. c23c016\$.ipc.) and ((belt web) near4 (substrate wafer)).ti.) not (canon\$.as. and ((belt web) near4 (substrate wafer))))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:12
-	39	(((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) with (electrode cathode anode))) not (((h011021\$.ipc. c23c016\$.ipc.) and ((belt web) near4 (substrate wafer)).ti.) not (canon\$.as. and ((belt web) near4 (substrate wafer)))) not (canon\$.as. and ((belt web) near4 (substrate wafer))))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:25
-	29	(((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) same (electrode cathode anode))) not (((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) with (electrode cathode anode))) not (((h011021\$.ipc. c23c016\$.ipc.) and ((belt web) near4 (substrate wafer)).ti.) not (canon\$.as. and ((belt web) near4 (substrate wafer))))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:18
-	70	(((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) same (electrode cathode anode))) not (canon\$.as. and ((belt web) near4 (substrate wafer))))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:18

-	24	((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) same (electrode cathode anode))) not ((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) with (electrode cathode anode))) not (canon\$.as. and ((belt web) near4 (substrate wafer)))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:18
-	67	((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) same (flexible curv\$5 undulat\$4)))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:25
-	48	((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) same (flexible curv\$5 undulat\$4))) not (canon\$.as. and ((belt web) near4 (substrate wafer)))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:28
-	42	((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) same (flexible curv\$5 undulat\$4))) not (canon\$.as. and ((belt web) near4 (substrate wafer))) not ((h011021\$.ipc. c23c016\$.ipc.) and ((belt web) near4 (substrate wafer)).ti.)	USPAT; EPO; JPO; DERWENT	2002/11/22 16:04
-	6	((h011021\$.ipc. c23c016\$.ipc.) and (((belt web) near4 (substrate wafer)) same (flexible curv\$5 undulat\$4))) not (canon\$.as. and ((belt web) near4 (substrate wafer))) not ((h011021\$.ipc. c23c016\$.ipc.) and ((belt web) near4 (substrate wafer)).ti.) and ((flexible curv\$5 undulat\$4) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/22 11:29
-	34	canon\$.as. and ((belt web elongate) near4 (substrate wafer)) and ((electrode cathode anode) with (sheet columnar))	USPAT; EPO; JPO; DERWENT	2002/11/22 15:17
-	915	118/718.cccls.	USPAT; EPO; JPO; DERWENT	2002/11/22 17:17
-	206	118/718.cccls. and (electrode cathode anode)	USPAT; EPO; JPO; DERWENT	2002/11/22 15:33
-	98	118/718.cccls. and ((web belt elongate) near4 (substrate wafer))	USPAT; EPO; JPO; DERWENT	2002/11/22 15:20
-	70	(118/718.cccls. and (electrode cathode anode)) and (118/718.cccls. and ((web belt elongate) near4 (substrate wafer)))	USPAT; EPO; JPO; DERWENT	2002/11/22 15:20
-	136	(118/718.cccls. and (electrode cathode anode)) not ((118/718.cccls. and (electrode cathode anode)) and (118/718.cccls. and ((web belt elongate) near4 (substrate wafer))))	USPAT; EPO; JPO; DERWENT	2002/11/22 15:58
-	8	("4440107"   "4446816"   "4451501"   "4920917"   "4960072"   "5140938"   "5224441"   "5879741").PN.	USPAT	2002/11/22 15:36
-	8	("4440107"   "4446816"   "4451501"   "4920917"   "4960072"   "5140938"   "5224441"   "5879741").PN.	USPAT	2002/11/22 15:37
-	5	("4440107"   "4446816"   "4920917"   "4960072"   "5140938").PN.	USPAT	2002/11/22 15:44
-	28	(118/718.cccls. and ((web belt elongate) near4 (substrate wafer))) not (118/718.cccls. and (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/22 15:58
-	28	((118/718.cccls. and ((web belt elongate) near4 (substrate wafer))) not (118/718.cccls. and (electrode cathode anode))) not ((118/718.cccls. and (electrode cathode anode)) and (118/718.cccls. and ((web belt elongate) near4 (substrate wafer))))	USPAT; EPO; JPO; DERWENT	2002/11/22 15:58

-	957	(h011021\$.ipc. c23c016\$.ipc.) and (electrode and segment\$2)	USPAT; EPO; JPO; DERWENT	2002/11/22 16:05
-	375	(h011021\$.ipc. c23c016\$.ipc.) and (electrode same segment\$2)	USPAT; EPO; JPO; DERWENT	2002/11/22 16:24
-	582	((h011021\$.ipc. c23c016\$.ipc.) and (electrode and segment\$2)) not ((h011021\$.ipc. c23c016\$.ipc.) and (electrode same segment\$2))	USPAT; EPO; JPO; DERWENT	2002/11/22 16:24
-	36	((h011021\$.ipc. c23c016\$.ipc.) and (electrode and segment\$2)) not ((h011021\$.ipc. c23c016\$.ipc.) and (electrode same segment\$2))	JPO; DERWENT	2002/11/22 16:34
-	9638	(substrate wafer) with (curv\$5 flexible bend\$3 shap\$3 undulat\$3) with (electrode cathode anode)	JPO; DERWENT	2002/11/22 16:36
-	2438	(h011021\$.ipc. c23c016\$.ipc.) and (substrate wafer) with (curv\$5 flexible bend\$3 shap\$3 undulat\$3) with (electrode cathode anode)	JPO; DERWENT	2002/11/22 18:48
-	2	118/718.ccls. and (substrate wafer) same (curv\$5 flexible bend\$3 shap\$3 undulat\$3) same (electrode cathode anode)	JPO; DERWENT	2002/11/22 16:38
-	33	118/718.ccls. and (substrate wafer) same (curv\$5 flexible bend\$3 shap\$3 undulat\$3) with (electrode cathode anode)	USPAT; EPO; JPO; DERWENT	2002/11/22 16:41
-	26	118/718.ccls. and (substrate wafer) with (curv\$5 flexible bend\$3 shap\$3 undulat\$3) with (electrode cathode anode)	USPAT; EPO; JPO; DERWENT	2002/11/22 16:45
-	7	(118/718.ccls. and (substrate wafer) same (curv\$5 flexible bend\$3 shap\$3 undulat\$3) with (electrode cathode anode)) not (118/718.ccls. and (substrate wafer) with (curv\$5 flexible bend\$3 shap\$3 undulat\$3) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/22 16:46
-	30	118/718.ccls. and ((electrode cathode anode) with (sheet bundle\$ column\$2))	USPAT; EPO; JPO; DERWENT	2002/11/22 17:35
-	32	118/718.ccls. and ((electrode cathode anode) with (sheet\$ bundle\$ column\$2))	USPAT; EPO; JPO; DERWENT	2002/11/22 17:41
-	43	118/718.ccls. and ((electrode cathode anode) same (sheet bundle column columnar))	USPAT; EPO; JPO; DERWENT	2002/11/22 18:19
-	13	(118/718.ccls. and ((electrode cathode anode) same (sheet bundle column columnar))) not (118/718.ccls. and ((electrode cathode anode) with (sheet\$ bundle\$ column\$2)))	USPAT; EPO; JPO; DERWENT	2002/11/22 18:19
-	68	118/718.ccls. and ((electrode cathode anode) with (mov\$ lift\$3 up down rais\$3 actuat\$3))	USPAT; EPO; JPO; DERWENT	2002/11/22 18:44
-	3150	((electrode cathode anode) same (mov\$ lift\$3 up down rais\$3 actuat\$3) same ((compressed adj air) nitrogen "N2"))	USPAT; EPO; JPO; DERWENT	2002/11/22 18:47
-	2944	((electrode cathode anode) same (moving move moves lift\$3 up down rais\$3 actuat\$3) same ((compressed adj air) nitrogen "N2"))	USPAT; EPO; JPO; DERWENT	2002/11/22 18:49
-	125	(h011021\$.ipc. c23c016\$.ipc.) and (((electrode cathode anode) same (moving move moves lift\$3 up down rais\$3 actuat\$3) same ((compressed adj air) nitrogen "N2")))	JPO; DERWENT	2002/11/22 18:49
-	125	((h011021\$.ipc. c23c016\$.ipc.) and (((electrode cathode anode) same (moving move moves lift\$3 up down rais\$3 actuat\$3) same ((compressed adj air) nitrogen "N2")))) not (118/718.ccls. and ((electrode cathode anode) with (mov\$ lift\$3 up down rais\$3 actuat\$3)))	USPAT; EPO; JPO; DERWENT	2002/11/22 18:49

-	1027	427/569.ccls.	USPAT; EPO; JPO	2002/11/25 19:04
-	99	427/569.ccls. and ((belt web elongate long) with (substrate wafer))	USPAT; EPO; JPO	2002/11/25 19:06
-	111	427/569.ccls. and ((belt strip web elongate long) with (substrate wafer))	USPAT; EPO; JPO	2002/11/25 19:16
-	4	427/569.ccls. and ((belt strip web elongate long) same (substrate wafer))	JPO; DERWENT	2002/11/25 19:22
-	39	427/569.ccls. and (gas with pressure with (mov\$3 lift\$ rais\$3))	USPAT; EPO; JPO; DERWENT	2002/11/25 19:29
-	42	118/729.ccls. and (gas with pressure with (mov\$3 lift\$ rais\$3))	USPAT; EPO; JPO; DERWENT	2002/11/25 19:54
-	608	118/723R.ccls.	USPAT; EPO; JPO; DERWENT	2002/11/25 19:31
-	959	118/723e.ccls.	USPAT; EPO; JPO; DERWENT	2002/11/25 19:31
-	915	118/718.ccls.	USPAT; EPO; JPO; DERWENT	2002/11/25 19:31
-	22	118/718.ccls. and 118/723R.ccls.	USPAT; EPO; JPO; DERWENT	2002/11/25 19:32
-	64	118/718.ccls. and 118/723e.ccls.	USPAT; EPO; JPO; DERWENT	2002/11/25 19:33
-	57	(118/718.ccls. and 118/723e.ccls. ) not (118/718.ccls. and 118/723R.ccls. )	USPAT; EPO; JPO; DERWENT	2002/11/25 19:33
-	31	118/718.ccls. and (gas with pressure with (mov\$3 lift\$ rais\$3))	USPAT; EPO; JPO; DERWENT	2002/11/25 19:42
-	39	(427/569.ccls. and (gas with pressure with (mov\$3 lift\$ rais\$3))) not (118/718.ccls. and (gas with pressure with (mov\$3 lift\$ rais\$3)))	USPAT; EPO; JPO; DERWENT	2002/11/25 19:42
-	316	(h011021\$.ipc. c23c016\$.ipc.) and (gas with (mov\$3 lift\$ rais\$3) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/25 19:57
-	315	(h011021\$.ipc. c23c016\$.ipc.) and (gas with (mov\$3 lift\$ rais\$3) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/25 20:52
-	2787	(pressure with (mov\$3 lift\$ rais\$3) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/25 20:50
-	1674	((nitrogen air) with (mov\$3 lift\$ rais\$3) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/25 20:51
-	1933	((nitrogen air) with (mov\$3 lift\$ rais\$3 actuat\$3) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/25 20:52
-	77	(h011021\$.ipc. c23c016\$.ipc.) and ((nitrogen air) with (mov\$3 lift\$ rais\$3 actuat\$3) with (electrode cathode anode))	USPAT; EPO; JPO; DERWENT	2002/11/25 20:54
-	46	((h011021\$.ipc. c23c016\$.ipc.) and ((nitrogen air) with (mov\$3 lift\$ rais\$3 actuat\$3) with (electrode cathode anode))) not ((h011021\$.ipc. c23c016\$.ipc.) and (gas with (mov\$3 lift\$ rais\$3) with (electrode cathode anode)))	USPAT; EPO; JPO; DERWENT	2002/11/25 21:04
-	3	"02217399"	USPAT; EPO; JPO; DERWENT	2002/11/25 23:20